

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:  
Nozawa et al.  
Serial No.: 10/667,823  
Filed: September 22, 2003  
For: Phase Mask Shift Blank, Photo Mask Blank,  
And Manufacturing Apparatus And Method  
Of Blanks  
Examiner: Rodney Glenn McDonald  
Confirmation No.: 1017  
Art Unit: 1753

Commissioner of Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT D**

Dear Sir:

In response to the Office Action of July 19, 2006, please amend the above-identified application as follows: